Recitation 5: Review on Electrostatics

This review is aimed at getting ready for p-n junction. Before the class, have an exercise on the Boltzman relationship:

- 1. If the doping of Si is 10^{16} Boron, what should be the corresponding electrostatic potential be? ($\phi = -6 \times 60 = -360 \text{ mV}$)
- 2. If $\phi = 480 \text{ mV}$, what is equilibrium electron concentration? $\left(\frac{480}{60} = 8, n_o = 10^{18} \text{ cm}^{-3}\right)$
- 3. If doping is $N_d = 10^{20} \,\mathrm{cm}^{-3}, \phi = ? \ (\phi \neq 600 \,\mathrm{mV}, \phi = \phi_{\mathrm{max}} = 550 \,\mathrm{mV})$

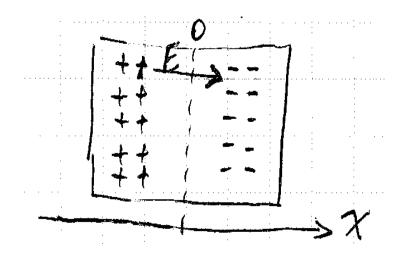
The following is the set of equations which relates $\rho(x)$, E(x), $\phi(x)$ needed for this class (everything is 1D):

1. Relating charge density to the field:

$$\frac{dE}{dx} = \frac{\rho(x)}{\epsilon}$$

or $E(x) - E(0) = \frac{1}{\epsilon} \int_0^x \rho(x') \, dx'$

 $\rho(x) = \text{charge density in coloumb/cm}^3, \epsilon \text{ is permittivity or dielectric constant of the material in F/cm}, \epsilon_o(\text{vacuum}) = 8.85 \times 10^{-14} \text{ F/cm}.$



2. Relating electrostatic potential to the field:

$$\frac{d\phi}{dx} = -E(x)$$

or $\phi(x) - \phi(0) = -\int_0^x E(x') dx'$

E(x) has units V/cm and $\phi(x)$ has units of V or mV.

- 3. Boundary conditions:
 - Continuation of potential at a boundary (infinite field inside semiconductor not possible)

$$\phi(x_h^-) = \phi(x_h^+)$$

- E-field at the boundary can (usually) have a jump, due to:
 - Materials change:

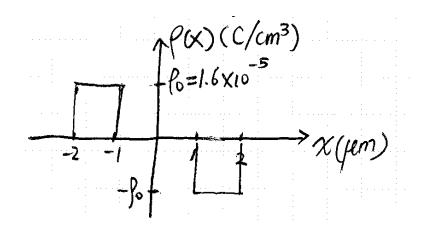
$$\int_{-\Delta}^{\Delta} d(\epsilon E(x)) = \epsilon_2 E(x = \Delta) - \epsilon_1 E(x = -\Delta)$$
$$= \int_{-\Delta}^{\Delta} \rho(x) \, dx = 0 \text{ no charge at interface}$$
$$E(0^+) = \frac{\epsilon_1}{\epsilon_2} E(0^-)$$

- A sheet of charge at the interface:

$$\int_{-\Delta}^{\Delta} d(\epsilon E(x)) = \epsilon_2 E(x = \Delta) - \epsilon_1 E(x = -\Delta)$$
$$= \int_{-\Delta}^{\Delta} \rho(x) \, dx = Q \text{ coulomb/cm}^2$$
$$E(0^+) = \frac{\epsilon_1}{\epsilon_2} E(0^-) + \frac{Q}{\epsilon_2}$$

Examples

Like in Figure 1



Then, let us work out E(x), by splitting calculations into 4 regions: 1. $E(x \le -2 \,\mu\text{m}) = E(x \ge 2 \,\mu\text{m})$ (:: no charge outside these regions)

2. For $-2\,\mu m < x < -1\,\mu m$:

$$\begin{split} E(x) - E(-2\,\mu\text{m}) &= \frac{1}{\epsilon_s} \int_{-2}^{x} \rho(x) \, dx = \frac{1}{\epsilon_s} \rho_o \cdot (x+2) \\ \rho_o &= 1.6 \times 10^{-5} \,\text{C/cm}^3 = 1.6 \times 10^{-17} \,\text{C/cm}^3 \\ \text{Particularly}, E(-1\,\mu\text{m}) &= \frac{1}{\epsilon_s} \rho_o \times 1\,\mu\text{m} \\ \text{Since } \epsilon_s &= 1 \times 10^{-12} \,\text{F/cm}, \\ E(-1\,\mu\text{m}) &= \frac{1.6 \times 10^{-5} \times 10^{-4} \,\text{C/cm}^3 \times \text{cm}}{1 \times 10^{-12} \,\text{F/cm}} = 1.6 \times 10^3 \,\text{V/cm} \end{split}$$

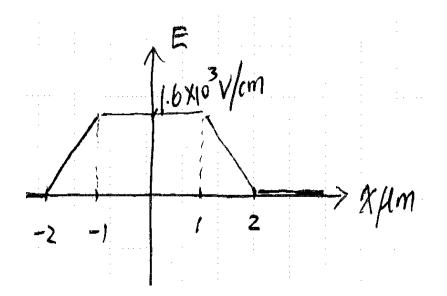
3. For $-1 < x < 1 \,\mu\text{m}$:

$$\rho(x) = 0$$
, same dielectric material $\implies E$ constant
 $E(x) = E(-1 \,\mu\text{m}) = 1.6 \times 10^3 \,\text{V/cm}$

4. For $1 < x < 2 \,\mu \text{m}$:

$$E(x) - E(1\,\mu\mathrm{m}) = \frac{1}{\epsilon_s} \int_1^x \rho(x) \, dx = -\frac{1}{\epsilon_s} \rho_o(x-1)$$

particularly, $E(2\,\mu\mathrm{m}) = E(1\,\mu\mathrm{m}) - \frac{1}{\epsilon_s} \rho_o(x-1) \Big|_{x=2\,\mu\mathrm{m}} = 0$



Now for the electrostatic potential:

As we do the integration, the results will be relative. Then we can use the doping of Si to find the actual value. For this thought-example, let us make $\phi(0) = 0$. For $0 < x < 1 \,\mu\text{m}$, $E(x) = \text{constant} = 1.6 \times 10^3 \,\text{V/cm}$.

$$\phi(x) - \phi(0) = -\int_0^x E(x') dx' = -1.6 \times 10^3 \cdot x \text{ (V/cm} \cdot \mu\text{m)}$$

particularly $\phi(1 \, \mu\text{m}) = -0.16V$

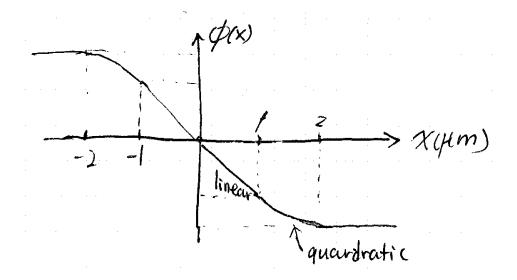
For $1 < x < 2 \,\mu m$,

$$\begin{split} \phi(x) &- \phi(1\,\mu\mathrm{m}) &= -\int_{1}^{x} E(x')\,dx' \\ &= -\int_{1}^{x} (1.6 \times 10^{3}\mathrm{V/cm} - \frac{1}{\epsilon_{\mathrm{s}}}\rho_{\mathrm{o}}(\mathrm{x}'-1))\,\mathrm{dx}' \\ &= -1.6 \times 10^{3}\,\mathrm{V/cm}\,(\mathrm{x}-1) + \frac{1}{2\epsilon_{\mathrm{s}}}\rho_{\mathrm{o}}(\mathrm{x}-1)^{2}\,\mathrm{quadratic} \\ \end{split}$$
particularly, $\phi(2\,\mu\mathrm{m}) &= \phi(1\,\mu\mathrm{m}) - 1.6 \times 10^{3}\,\mathrm{V/cm}\cdot(1 \times 10^{-4})\,\mathrm{cm} + \frac{1}{2}\frac{1.6 \times 10^{-5}\,\mathrm{C/cm}^{3}}{1 \times 10^{-12}\,\mathrm{F/cm}}\cdot(1 \times 10^{-8}\,\mathrm{cm}^{2}) \\ &= -0.16V - 0.08V = -0.24V \end{split}$

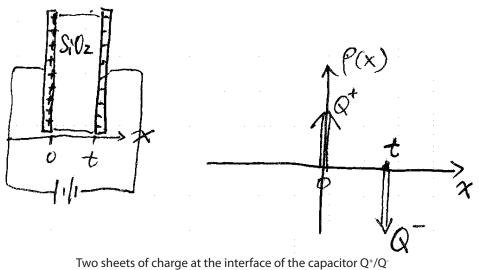
For $x > 2 \,\mu\text{m}$:

 $\therefore E(x) = 0$ electrostatic potential will be constant

Similarly, we can work out the other side:



Parallel Plate Capacitor



In 1D, this can be modeled as δ function

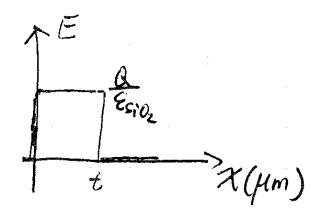
Now let us consider the electric field: Inside the metal, no charge, no field, $\implies E(x < 0) = E(x > t_d) = 0$:

$$\epsilon_{\rm SiO_2} - 0 = \int_{0^-}^{0^+} \rho(x') \, dx' = \int_{0^-}^{0^+} \delta(x) \, dx = Q$$

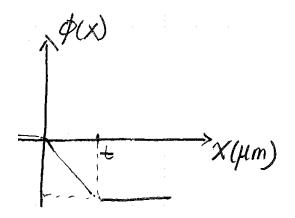
$$\therefore E(0^+) = \frac{Q}{\epsilon_{\rm SiO_2}}$$

$$\epsilon_{\rm SiO_2} = 3.45 \times 10^{-13} \, {\rm F/cm}$$

As there is no charge inside SiO_2 region, E is constant $E(x) = \frac{Q}{\epsilon_{\rm SiO_2}} \, {\rm for} \, 0 < x < t$



If we use $\phi(0) = 0$ again,



6.012 Microelectronic Devices and Circuits Spring 2009

For information about citing these materials or our Terms of Use, visit: http://ocw.mit.edu/terms.